

On page 3, at the top of the page, please insert the following heading:

--Summary of the Invention--.

On page 8, between lines 4 and 5, please insert the following heading:

B¹ --Brief Description of the Drawing--;

On page 9, between lines 11 and 12, please insert the following heading:

B² --Description of Preferred Embodiments--.

On page 10, line 14, please delete "underside" and insert -- surface --.

The substrate holder 5 comprises a base plate 8 which, on the upper side thereof that faces the transport device, is provided with a recess 10 for the appropriate accommodation of the rotary shaft 6. The substrate holder 5 is rotationally symmetrical relative to an axis of rotation A of the rotary shaft 6. A recess 12 for receiving a substrate 13 is formed in the underside 11 of the base plate 8, which underside faces away from the transport device. The substrate 13 is accommodated in the recess 12 in such a way that a surface 15 of the substrate that is to be coated faces away from the substrate holder and is exposed. The depth of the recess 12 corresponds to the thickness of the substrate that is to be accommodated, so that the underside 11 of the base plate 8 is flush with the surface 15 of the substrate that is to be coated when the substrate 13 is inserted into the recess. However, if desired, the surface 15 can also be spaced from the plane defined by the underside 11 of the base plate 8, and in particular can project downwardly beyond the underside 11. The substrate 13 is held on the substrate holder 15 by non-illustrated vacuum openings that are formed in the base plate and communicate with a non-illustrated source of vacuum, such as a

vacuum pump.

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On page 13, line 19, please delete "underside 11" and insert --main body 8--.

The substrate holder 5 again has a base plate 8, which on its upper side is provided with a recess 10 for receiving a rotary shaft. In contrast to the embodiment of Figs. 1-6, the underside 11 of the main body 8 that faces the substrate is not provided with a recess for accommodating the substrate 13. The main body 8 is flat, and the substrate 13 is held against the base plate 8 via vacuum openings 50 in the main body 11. As was the case with the first embodiment of Figs 1-6, the vacuum openings 50 are in contact with a vacuum source. Formed in the underside 11 of the main body 8 is a groove that surrounds the vacuum openings 50 for receiving a sealing element, such as an O-ring 52.

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On page 14, line 23, please delete "B" and insert -- 13 --.

The cover 20 is again provided with a central wall 28 having a central plane B to which the upper and lower sides of the cover 20 are symmetrical. Therefore, again only the upper portion of the cover 20 will be described. A circumferential flange 30 having a planar upper surface 31 again extends upwardly in the outer region of the central wall 28. The flange is rotationally symmetrical relative to the central axis C, which pursuant to Fig. 7 coincides with the axis of rotation A of the substrate holder 5. The flange 30 is again provided with a notch 32 that is adjacent to and flush with the central wall. By means of the notch 32, an inwardly extending projection 34 of the flange 30 is formed. The inner periphery 62 of the projection is dimensioned such that a substrate 13 that is to be coated can be received within or between the projection without contacting the

same. The notch 32 has an inclined upper side 60, so that the notch 32 is tapered radially outwardly.

On page 15, line 8, please delete "main body 5" and insert -- main body 8 --.

The flange 30 has a further projection 64 that extends axially from the planar upper surface 31 and defines a downwardly tapering inner peripheral surface 66. The downwardly tapering inner peripheral surface 66 is adapted to the outer peripheral shape of the substrate holder 5 and forms a slanted centering portion, so that the main body 8 can slide along the inner peripheral surface 66 until the underside 11 of the main body 8 of the substrate holder 5 rests upon the planar upper surface 31 of the flange 30 of the cover 20. By means of the tapering inner circumferential shape, a centering of the substrate holder 5 relative to the cover 20, and hence a centering of the substrate 13 relative to the substrate holder 5, is ensured.

On page 19, line 5, please insert the following two new paragraphs.

³
B The specification incorporates by reference the disclosure of German priority document 199 06 398.2 of 16 February 1999 and International priority document PCT/EP00/00380 of 19 January 2000.

The present invention is, of course, in no way restricted to the specific disclosure of the specification and drawings, but also encompasses any modifications within the scope of the appended claims.

IN THE CLAIMS:

✓
Please cancel claims 1 - 29, and replace them with the attached claims 30 -

57.

IN THE DRAWINGS:

Please replace page 1 of the drawings with the attached, which shows corrections highlighted in blue marker. This is a copy of page 1 of the drawing. The originally submitted page 1 may be a more useful copy with changes noted in red.